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Supporting Information

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Synthesis of Nanoamorphous Germanium and Its Transformation to Nanocrystalline Germanium

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Supporting Information

Synthesis of Amorphous Germanium Nanoclusters and Their Transformation to Nanocrystals

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Figure S1. UV-Vis-NIR spectra of 0.11 ml Ge(OCH₂CH₃)₄, 0.36 ml (CH₃CH₂O)₃SiH in 12 ml ethanol and 3 ml water: (a) fully reacted sample, diluted i) 300, ii) 150, iii) 100, iv) 75, v) 50, vi) 30 and vii) 15 times, (b) normalized spectra in (a), (c) time dependent spectral change (between 5 min to 5 days (1) 8 min, 2) 15 min, 3) 21 min, 4) 28 min, 5) 35 min, 6) 45 min, 7) 92 min, 8) 150 min, 9) 270 min, 10) 415 min, 11) 755 min, 12) 1170 min, 13) 3413 min, and 14) 7360 min), (d) normalized spectra 1 to 9 of (c), (e) i) of partially reacted (30 min) and completely reacted and diluted sample, and (f) indicating determination of the onset energy.



Figure S2. Photoluminecence (PL) spectra of a mixture of 0.11ml Ge(OC₂H₅)₄ and 0.36 ml HSi(OC₂H₅)₃ in a 3 ml CH₃OH/0.5 ml H₂O after (2) 45 min, (3) 100 min, (4) 140 min, (5) 190 min, (6) 265 min, (7) 28 h, (8) 95 h, and (9) 5 weeks. (a) normalized to CH₃OH (1) peak at 1033 cm⁻¹, (b) normalized with respect to PL maximum of (4) and (8), and the convolutions of (c) (4) and (d)(8).

Figure S3. HAADF TEM images of na-Ge upon HF etching.

Figure S4. (a) Diffuse reflectance UV-Vis-NIR spectra of na-Ge/SiO₂ over time (as indicated in the spectra). (b) Tauc plot of the fresh sample $((A^*h\nu)^{1/2}$ versus hv plot, valid for indirect semiconductors).

Figure S5. The ²⁹Si HPDEC MAS NMR Spectra of (a) fresh and (b) 30 days aged na-Ge/SiO₂ sample.

Figure S6. The band gap energy versus particle diameter plots of nc-Ge and na-Ge using effective mass model.

Figure S7. (a) HAADF TEM and (b) TEM images of the nc-Ge/SiO₂ recorded from different parts of the sample.

Figure S8. EDS spectrum of nc-Ge/SiO₂.

Figure S9. UPS spectrum of nc-Ge.

Figure S10. HR-TEM image showing 3-4 nm nc-Ge.

Figure S11. XPS survey scan of nc-Ge after HF etching.